Search History. (5 pp.). [signature] (3/1/05).

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	2	("6090443").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/01 08:14
L2	0	("oxygenadjdiffusionandferroelectricadjcapacitor").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/01 08:14
L3	171	oxygen adj diffusion and ferroelectric adj capacitor	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/01 08:15
L4	41	oxygen adj diffusion.ti,ab,clm. and ferroelectric adj capacitor	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/01 08:15
L5	27	oxygen adj diffusion.ti,ab,clm. and ferroelectric adj capacitor.ti,ab,clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/01 08:15
L6	28	(US-20020074601-$ or US-20020195633-$ or US-20030211685-$ or US-20040238862-$ or US-20020137301-$ or US-20020135067-$).did. or (US-6611014-$ or US-6090443-$ or US-6613640-$ or US-6566753-$ or US-6479304-$ or US-6399521-$ or US-6236113-$ or US-6146963-$ or US-6072689-$).did. or (EP-1054440-$ or EP-1035589-$ or EP-821415-$).did. or (JP-2001036026-$ or JP-2003273323-$ or JP-2001118941-$).did. or (JP-2001036026-$ or US-20040195613-$ or US-20040180453-$ or US-20040129670-$ or US-20040004236-$ or DE-10105997-$ or EP-905786-$).did.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2005/03/01 08:32

L7	28	(US-20020074601-$ or US-20020195633-$ or US-20030211685-$ or US-20040238862-$ or US-20020137301-$ or US-20020135067-$).did. or (US-6611014-$ or US-6090443-$ or US-6613640-$ or US-6566753-$ or US-6479304-$ or US-6399521-$ or US-6236113-$ or US-6146963-$ or US-6072689-$).did. or (EP-1054440-$ or EP-1035589-$ or EP-821415-$).did. or (JP-2001036026-$ or JP-2003273323-$ or JP-2001118941-$).did. or (JP-2001036026-$ or US-20040195613-$ or US-20040180453-$ or US-20040129670-$ or US-20040004236-$ or DE-10105997-$ or EP-905786-$).did.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2005/03/01 09:00
L8	28	7 and ferroelectric and capacitor	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/03/01 09:01
S1	3	"743073".ap.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/28 08:58
S2	180	(257/254).CCLS.	US-PGPUB; USPAT	OR	OFF	2005/02/28 08:58
S3	925	(257/734).CCLS.	US-PGPUB; USPAT	OR	OFF	2005/02/28 08:58
S4	0	S2 and S3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/28 08:58
S5	570	(438/254).CCLS.	US-PGPUB; USPAT	OR	OFF	2005/02/28 08:59
S6	429	(438/734).CCLS.	US-PGPUB; USPAT	OR	OFF	2005/02/28 08:59
S7	3	S5 and S6	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/28 09:05
S8	1547	(438/3).CCLS.	US-PGPUB; USPAT	OR	OFF	2005/02/28 09:05

S9	1039	(438/197).CCLS.	US-PGPUB; USPAT	OR	OFF	2005/02/28 09:05
S10	1060	(438/238).CCLS.	US-PGPUB; USPAT	OR	OFF	2005/02/28 09:05
S11	907	(438/239).CCLS.	US-PGPUB; USPAT	OR	OFF	2005/02/28 09:05
S12	1232	(438/240).CCLS.	US-PGPUB; USPAT	OR	OFF	2005/02/28 09:05
S13	2192	(438/253).CCLS.	US-PGPUB; USPAT	OR	OFF	2005/02/28 09:06
S14	1054	(438/706).CCLS.	US-PGPUB; USPAT	OR	OFF	2005/02/28 09:06
S15	7846	S5 S6 S8 S9 S10 S11 S12 S13 S14	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/28 09:06
S16	2688	S15 and (etching etchant etch) and (annealing anneal heat adj (treatment treating treated))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/28 10:14
S17	123	S16 and capacitor and second near3 (etching etch) near3 step	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/28 09:13
S18	0	S17 and ferroeelectric	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/28 09:14
S19	97	S16 and capacitor and second near3 (etching etch) near3 step and (anneal annealing)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/28 09:13
S20	35	S17 and ferroelectric	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/28 10:10
S21	6	S17 and ferroelectric and adhesion adj layer	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/28 10:12

S22	1	S17 and ferroelectric and adhesion adj layer near4 (etch etching etchant)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/28 10:12
S23	742	S15 and (etching etchant etch) and (annealing anneal heat adj (treatment treating treated)) and ferroelectric	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/28 10:14
S24	18	S15 and (etching etchant etch) and (annealing anneal heat adj (treatment treating treated)) and ferroelectric and (adhesion adhesive buffer) near2 (etch etching etchant)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/28 11:13
S25	2	jp-2001036026$-$.did.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/28 11:16
S26	3	("6611014").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/28 11:17
S27	7	(US-20040238862-$ or US-20020195633-$ or US-20030211685-$ or US-20020074601-$).did. or (US-6611014-$).did. or (JP-2001036026-$).did. or (JP-2001036026-$).did.	US-PGPUB; USPAT; JPO; DERWENT	OR	OFF	2005/02/28 15:31
S28	5	barrier and S27	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/28 15:58
S29	35	oxygen adj barrier near6 lower adj electrode and capacitor and ferroelectric	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/28 15:58
S30	7	(US-20020074601-$ or US-20020195633-$ or US-20030211685-$ or US-20040238862-$).did. or (US-6611014-$).did. or (JP-2001036026-$).did. or (JP-2001036026-$).did.	US-PGPUB; USPAT; JPO; DERWENT	OR	OFF	2005/03/01 06:59

| S31 | | 5 | S30 and (Ir IrO iridium iridium adj oxide "Ir.sub."$3"O") | US-PGPUB; USPAT; JPO; DERWENT | OR | OFF | 2005/03/01 08:09 |